

Volume 25 (2018)

**Supporting information for article:** 

The Implications of X-ray beam profiles on Qualitative and Quantitative Synchrotron Micro-Focus X-ray Fluorescence Microscopy

Alexander P. Morrell, J. Frederick W. Mosselmans, Kalotina Geraki, Konstantin Ignatyev, Hiram Castillo-Michel, Peter Monksfield, Adrian T. Warfield, Maria Febbraio, Helen M. Roberts, Owen Addison and Richard A. Martin

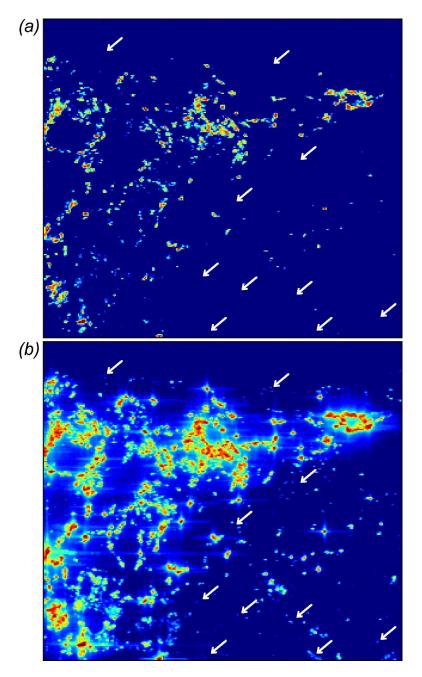
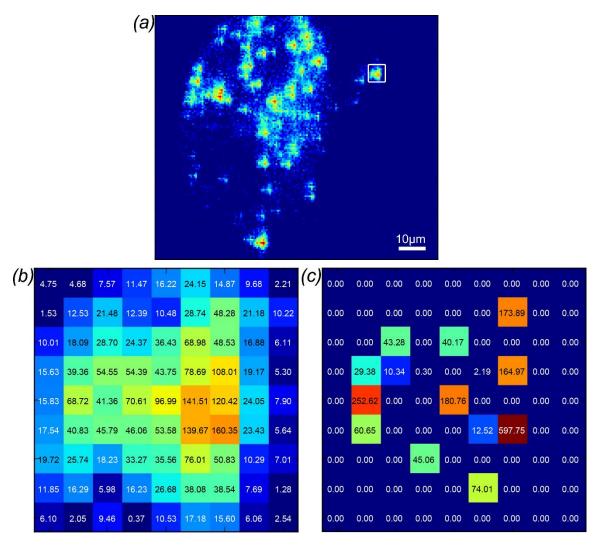


Figure S1 A large thresholding value is needed as the artefacts surrounding high concentration particles have a large magnitude. Image a is a result of the map after minimum thresholding, arrows are used to indicate some of the low concentration features which are lost during the thresholding procedure. As these areas are a substantial distance away from any high concentration particles, they are not artefacts.



**Figure S2** a. Original Ti XRF map highlighting regions shown in b and c (white box). b. Before the beam profile correction. c. After the beam profile correction.

**Table S1** Table listing the scaling factors used to calculate the beam contribution in the quadrants.

Letter	<u>a</u>	<u>b</u>	<u>c</u>	<u>d</u>	<u>e</u>	f	g
Scaling Factor	0.532	0.468	0.768	0.232	0.128	0.872	0.840

Letter	<u>h</u>	<u>i</u>	j	<u>k</u>	<u>l</u>	<u>m</u>
Scaling Factor	0.160	0.352	0.648	0.876	0.520	0.796

The code for both correction methods are available on GitHub:

- 1. Beam profile correction (https://github.com/morrella/Beam\_Profile\_Correction\_XRF)
- 2. Adaptive subtraction correction (https://github.com/morrella/Adaptive\_Subtraction\_XRF)